

Magneto-transport properties of MnGeP₂ ferromagnetic semiconductor

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The research for promising ferromagnetic semiconducting materials, with high magnetic moments and high Curie temperatures (T_C), is of the utmost importance spin-dependent electronic devices. We have synthesized a new semiconductor, MnGeP₂, whose crystal structure is chalcopyrites, which are "genealogically" related to the more familiar tetrahedrally-coordinated zinc-blende materials. MnGeP₂ exhibited ferromagnetism with $T_C = 320$ K and magnetic moment per Mn at 5K of 2.58 μ_B , comparable to the calculated 3.2 μ_B . The calculated electronic structure using the full-potential linearized augmented plane wave (FLAPW) method shows an indirect energy gap of 0.24eV. In this talk we will present the magneto-transport properties such as magnetoresistance and Hall resistance of MnGeP₂ thin film grown on GaAs(100) using molecular beam epitaxy. The temperature dependent resistance results strongly support the presence of ferromagnetic phase transition around 320 K. On the other hand, we observe an anomalous Hall effect in p-type ($\sim 10^{20}$ cm⁻³) MnGeP₂ thin film, indicating the presence of spin polarized hole carriers in MnGeP₂, which may be useful for the spintronic devices.